TRANSLEGAL, LLC

TRANSLATION OF GERMAN PATENT P2004.0327

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Summary

5 Process for structuring at least one layer as well as electrical component with structures from the layer

The invention states a process to generate at least one structured layer (10A), wherein a mask structure (20) with a first (20A) and second structure (20B) is generated on a layer (10) which is present on a substrate (5). Through this mask structure (20), the first layer (20A) is transferred onto the layer (10) using isotropic structuring processes, and the second structure (20B) is transferred onto the layer (10) using anisotropic structuring processes. The process as per the invention permits the generation of two structures (20A, 20B) in at least a single layer while using a single mask structure.

20 Significant figure: Figure 1

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